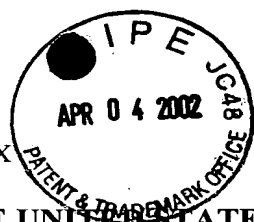


#74



Docket No. 0039-7632-0X

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF: Hiroyuki YANO, et al.

GAU: 1765

SERIAL NO: 09/531,163

EXAMINER: D.V. DEO

FILED: March 17, 2000

FOR: AQUEOUS DISPERSION, AQUEOUS DISPERION FOR CHEMICAL MECHANICAL POLISHING
USED FOR MANUFACTURE OF SEMICONDUCTOR DEVICES, METHOD FOR MANUFACTURE OF
SEMICONDUCTOR DEVICES, AND METHOD FOR FORMATION OF EMBEDDED WIRING

REQUEST FOR EXTENSION OF TIME
UNDER 37 C.F.R. 1.136

ASSISTANT COMMISSIONER FOR PATENTS
WASHINGTON, D.C. 20231

SIR:

It is hereby requested that a one month extension of time be granted to April 4, 2002 for

☐ filing a response to the Official Action dated:

☐ responding to the requirements in the Notice of Allowability dated:

☐ filing the Formal Drawings. The Issue Fee due

☐ responding to the Notice to File Missing Parts of Application dated:

**filing a Notice of Appeal. A timely Amendment and
Request for Reconsideration was filed on February 28,
2002. An Amendment and Request for Reconsideration w/**

☒ **Marked-Up Copy is being filed concurrently herewith.**

☐ filing an Appeal Brief. A Notice of Appeal was filed on:

☐ Applicant claims small entity status. See 37 CFR 1.27. Therefore, the fee amount shown below is reduced by one-half.

The required fee of \$110.00 is enclosed herewith by check and any further charges may be made against the Attorney of Record's Deposit Account No. 15-0030. A duplicate copy of this sheet is enclosed.

has been timely filed.

RECEIVED
APR - 9 2002
TC 1700

04/05/2002 HGBREM1 00000066 09531163

01 FC:115

110.00 OP

Respectfully Submitted,

OBLON, SPIVAK, McCLELLAND,
MAIER & NEUSTADT, P.C.

Stefan U. Koschmieder

Norman F. Oblon

Registration No. 24,618

Stefan U. Koschmieder

Registration No. 50,238



22850

Tel. (703) 413-3000
Fax. (703) 413-2220
(OSMMN 10/01)